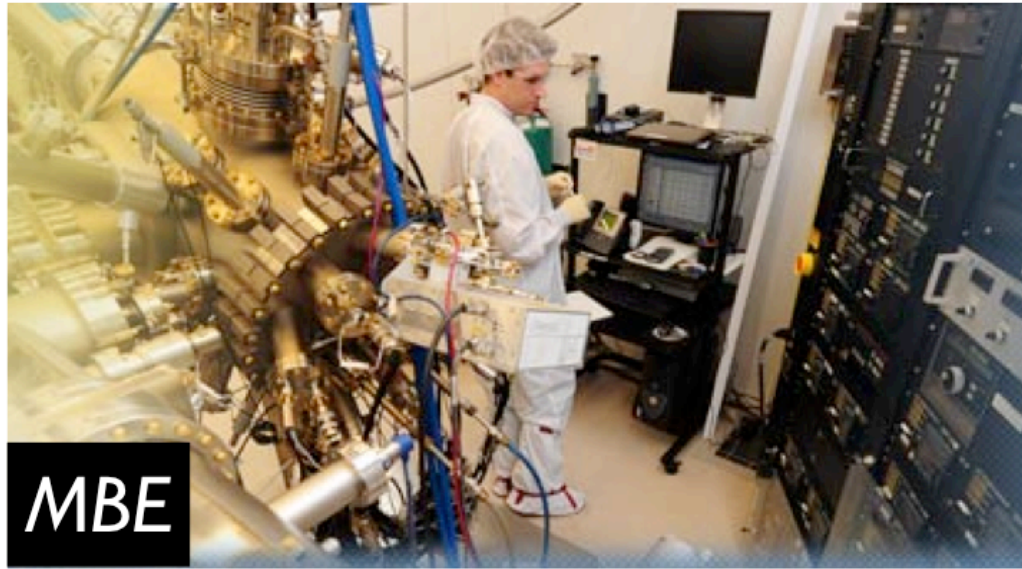


# Jena research group



MBE

Nitrides

Oxides

Layered

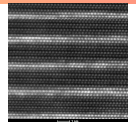
Electronic  
devices

Photonic  
devices

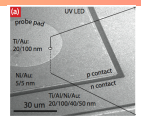
Physics-led theory and design of high-performance nanoelectronic and nanophotonic devices

$$\mathbf{J} = -\frac{ie\hbar}{2m}[\Psi^* \hat{\mathbf{p}} \Psi - \Psi \hat{\mathbf{p}} \Psi^*]$$

MBE growth and characterization of the designed quantum structures with atomic level control



Nanofabrication of nanoelectronic and nanophotonic devices with state of the art tools



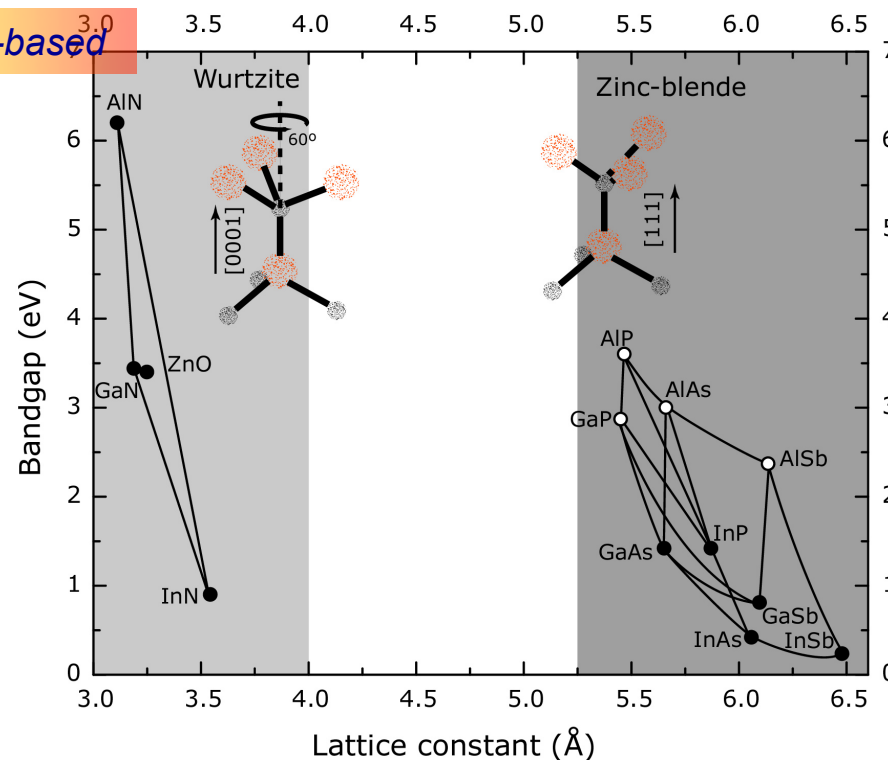
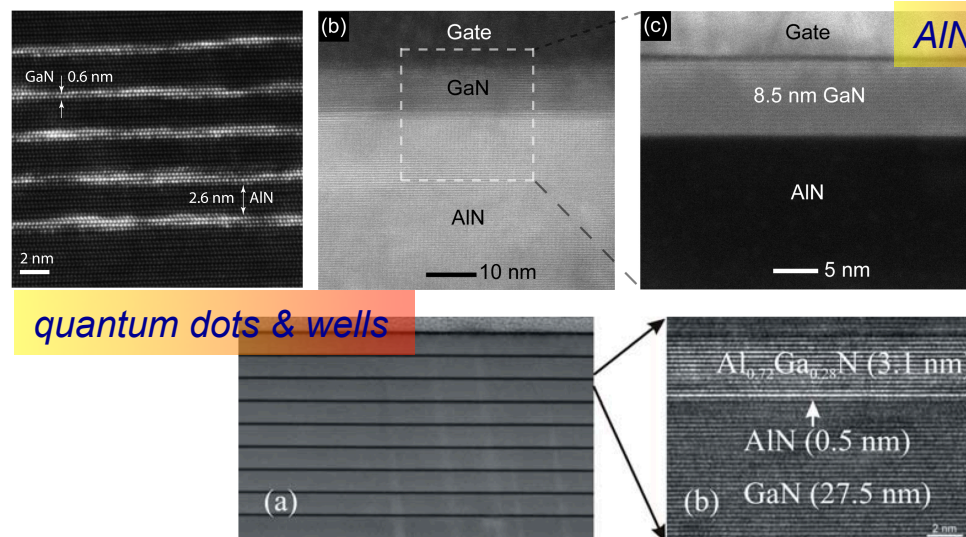
Measurement, characterization, and analysis of device performance, relate it to the device physics



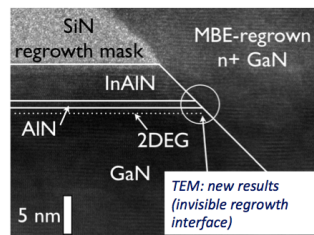
- We do Molecular Beam Epitaxy of quantum heterostructures
- We are currently working on semiconducting Nitrides, Oxides, and 2D Crystals
- We do a significant amount of modeling and design for materials to devices
- We do nanofabrication of new electronic and photonic devices with these materials

Debdeep Jena (djena@cornell.edu)

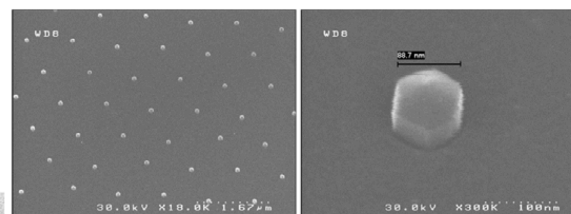
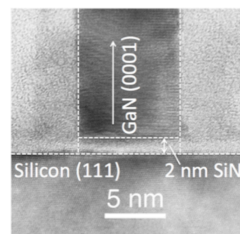
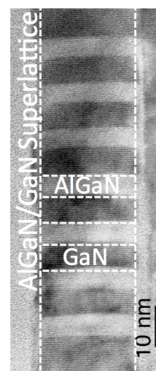
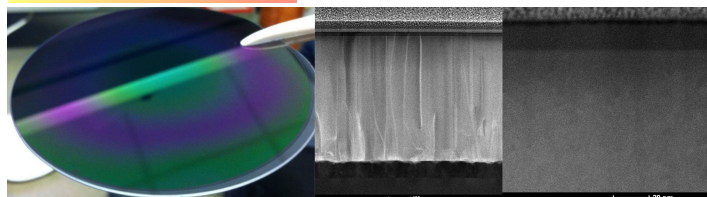
# Range of bandgaps, geometries, and platforms



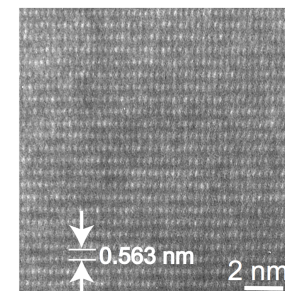
GaN-based HEMTs on SiC & sapphire



GaN on Silicon



Nanostructures & patterned heterostructures



InN

- III-Nitride nanostructures grown by MBE

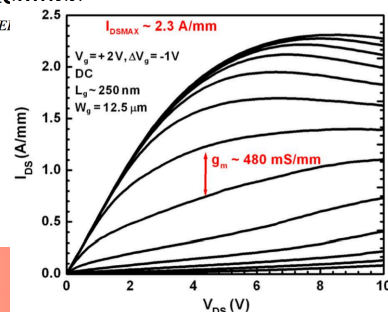
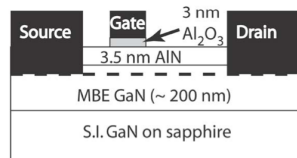


# Resulting Device Technologies

IEEE ELECTRON DEVICE LETTERS, VOL. 29, NO. 7, JULY 2008

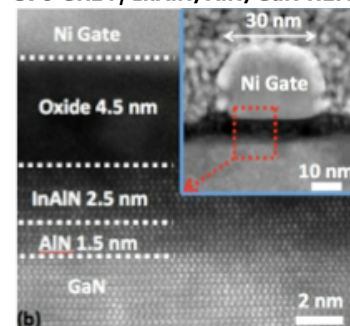
## AlN/GaN Insulated-Gate HEMTs With 2.3 A/mm Output Current and 480 mS/mm Transconductance

Tom Zimmermann, David Deen, Yu Cao, John Simon, Patrick Fay, *Senior Member, IEEE*  
Debddeep Jena, *Member, IEEE*, and Huili Grace Xing, *Member, IEEE*

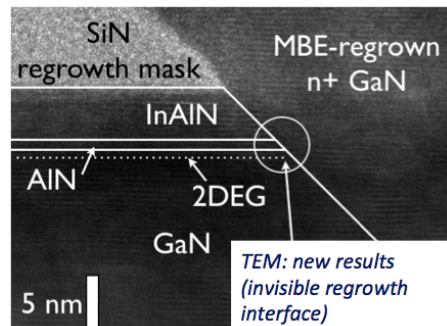


## Ultrascaled GaN HEMTs

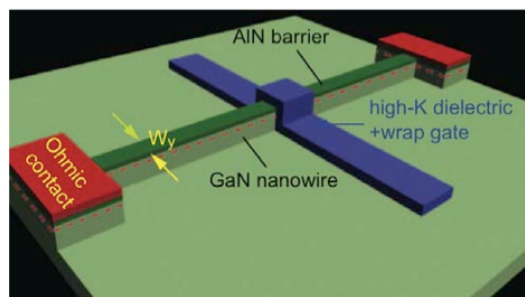
## 370 GHz $f_T$ InAlN/AlN/GaN HEMT



## 248/268 $f_{max}$ GaN D-mode HEMTs



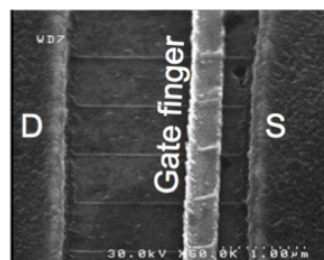
## High-speed GaN HEMTs



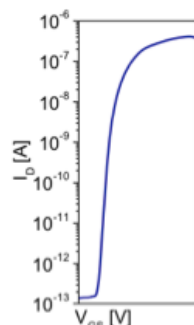
IEEE ELECTRON DEVICE LETTERS, VOL. 31, NO. 5, MAY 2012

## Ultrathin Body GaN-on-Insulator Quantum Well FETs With Regrown Ohmic Contacts

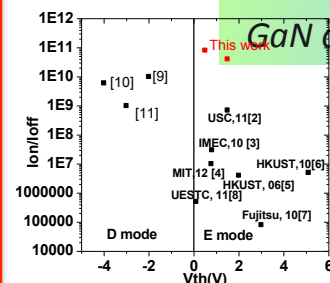
Guowang Li, *Student Member, IEEE*, Ronghua Wang, Jia Guo, *Student Member, IEEE*, Jai Verma, Zongyang Hu, Yuanzhong Yue, Faiza Faria, Yu Cao, Michelle Kelly, Thomas Kosel, Huili Xing, *Member, IEEE*, and Debddeep Jena, *Member, IEEE*



## Tri-gate HEMTs

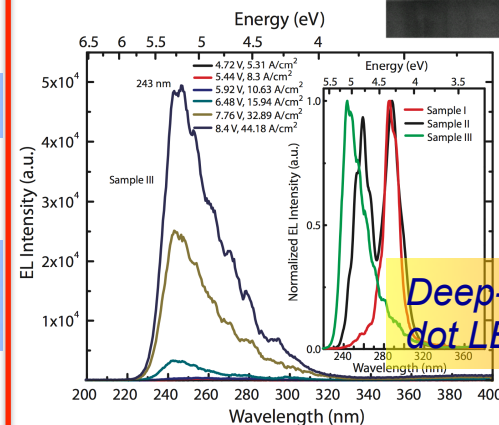
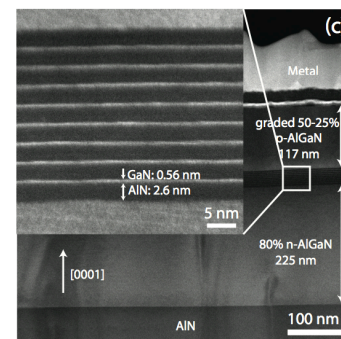
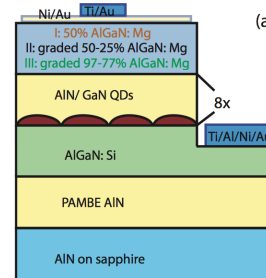


## GaN on Insulator (AlN)



## Hi-voltage GaN switches

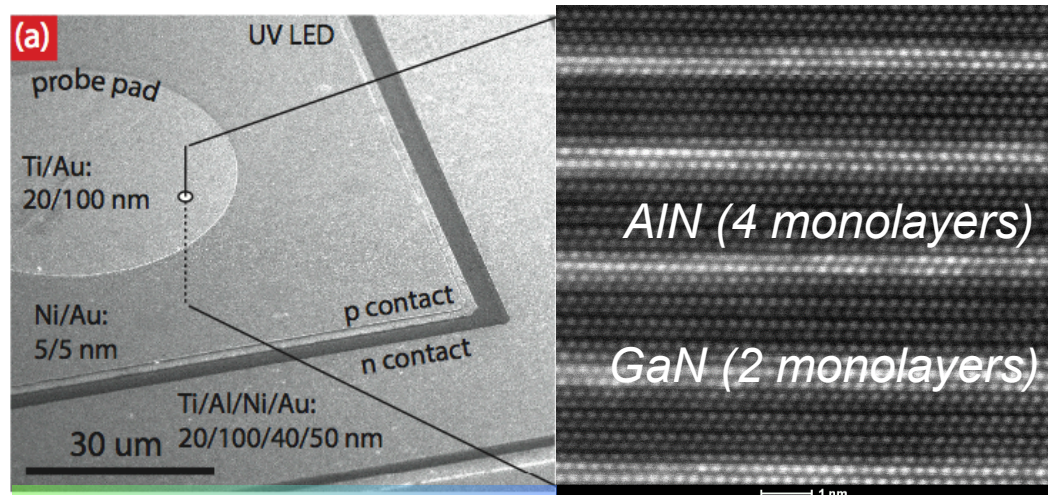
## Devices for Power Electronics



## Deep-UV quantum dot LEDs

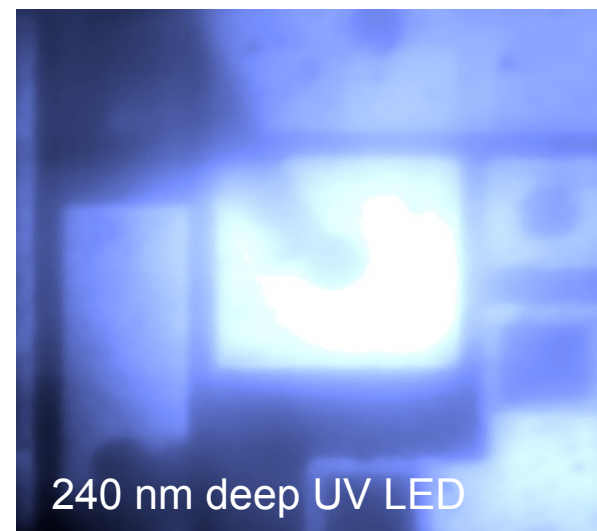
Debddeep Jena (djena@cornell.edu)

# Extreme Bandgap Materials and Devices

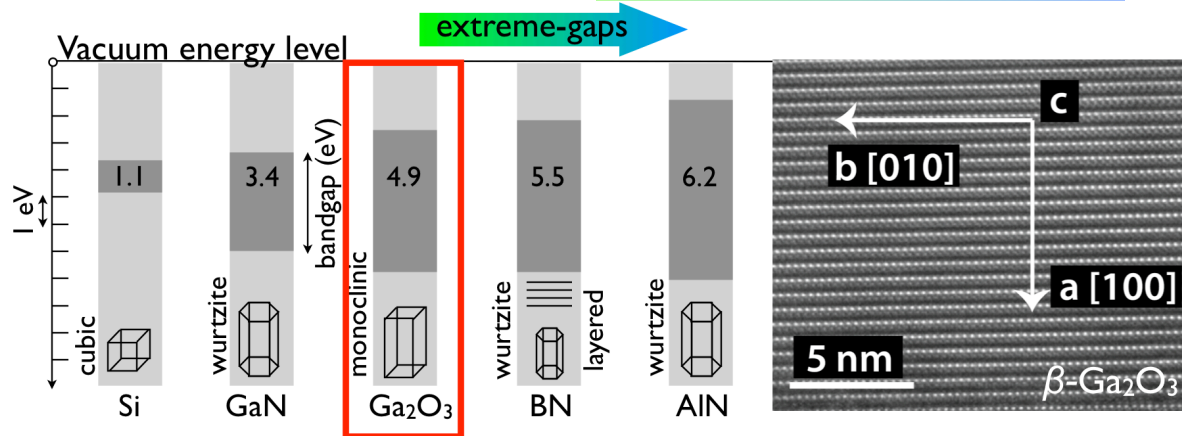


Nanofabrication

MBE growth with atomic level design and control



Photonic and electronic devices



## Polarization-Induced Hole Doping in Wide-Band-Gap Uniaxial Semiconductor Heterostructures

John Simon, Vladimir Protasenko, Chuanxin Lian, Huili Xing, Debdeep Jena\*

1 JANUARY 2010 VOL 327 SCIENCE www.sciencemag.org

- We are exploring next-generation extreme-gap semiconductor materials
- They are critical for energy, computation & communication applications in the next few decades

Debdeep Jena (djena@cornell.edu)



# 2D Crystal Materials and Devices

Increasingly challenging physics

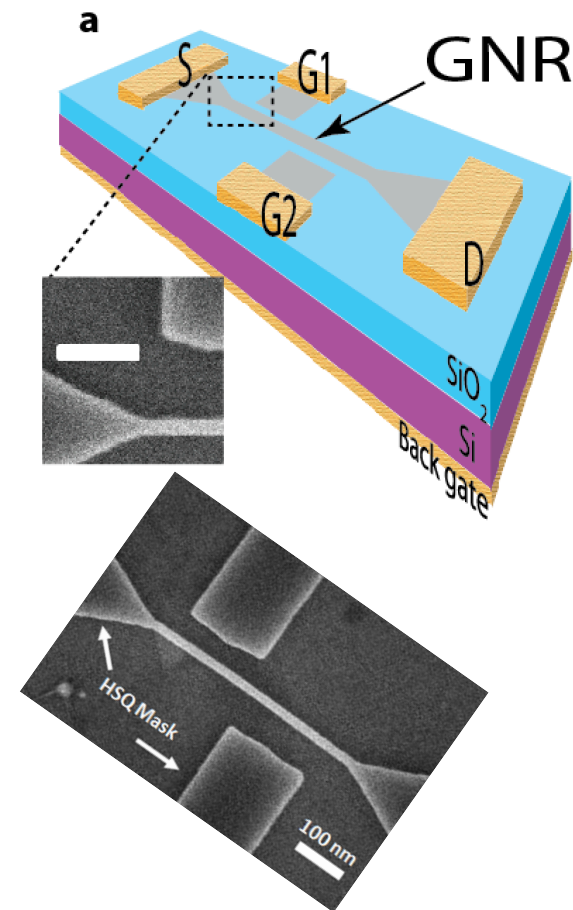
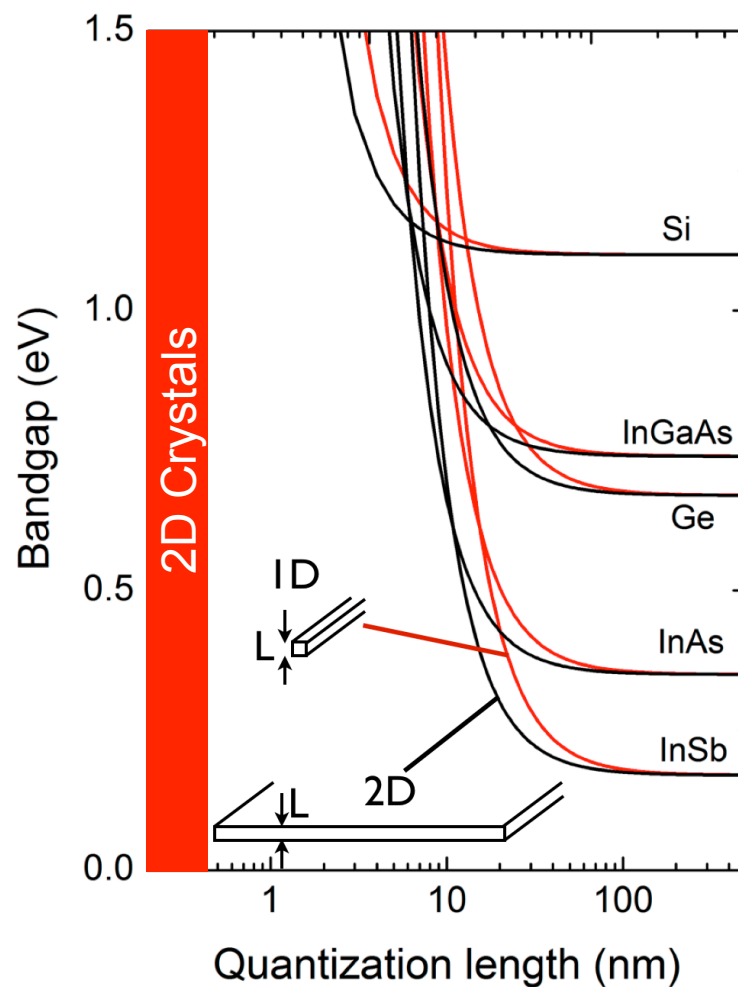
Ultrascaled FETs

In-plane TFETs

Interlayer TFETs

SymFETs

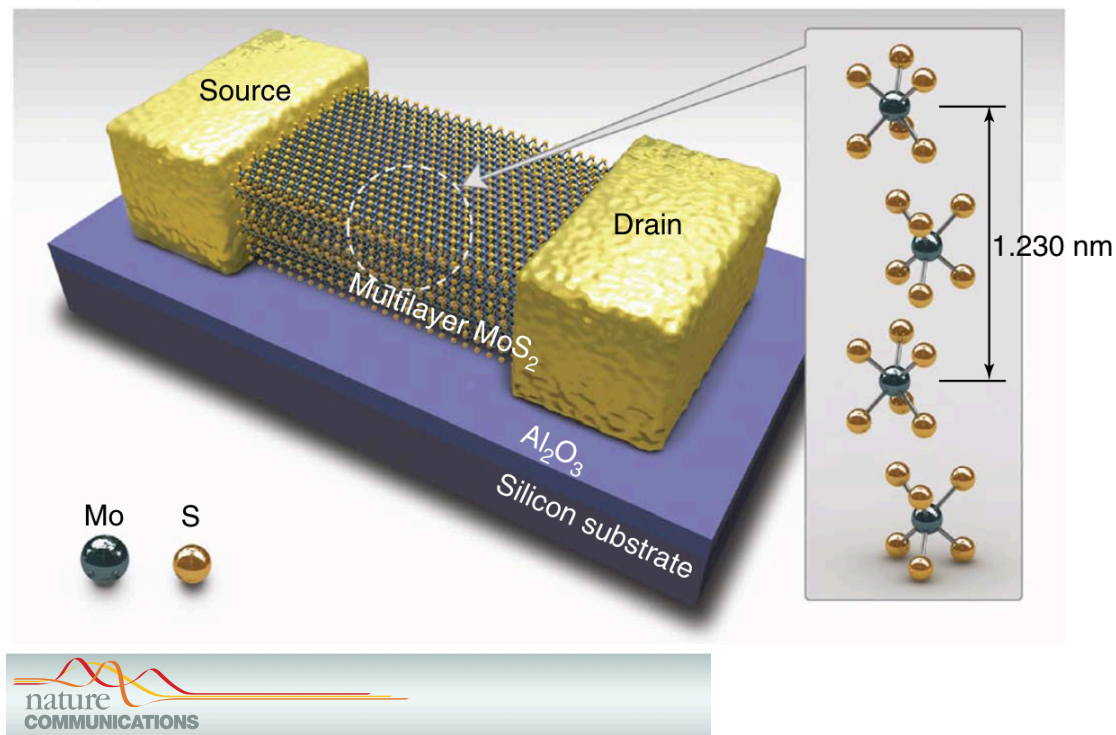
Tunable DOS FETs



- We are exploring materials that will take us beyond the scaling of traditional semiconductors
- 2D crystal materials: semiconducting, metallic, or superconducting – and remain atomically thin!

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# 2D Crystal Materials and Devices



## ARTICLE

Received 27 Feb 2012 | Accepted 23 Jul 2012 | Published 21 Aug 2012

DOI: 10.1038/ncomms2018

## High-mobility and low-power thin-film transistors based on multilayer MoS<sub>2</sub> crystals

Sunkook Kim<sup>1,2</sup>, Aniruddha Konar<sup>3</sup>, Wan-Sik Hwang<sup>3</sup>, Jong Hak Lee<sup>4</sup>, Jiyoul Lee<sup>1</sup>, Jaehyun Yang<sup>4</sup>, Changhoon Jung<sup>1</sup>, Hyoungsub Kim<sup>4</sup>, Ji-Beom Yoo<sup>4</sup>, Jae-Young Choi<sup>1</sup>, Yong Wan Jin<sup>1</sup>, Sang Yoon Lee<sup>1</sup>, Debdeep Jena<sup>3</sup>, Woong Choi<sup>1,5</sup> & Kinam Kim<sup>1</sup>

- Atomically thin semiconductor materials (Graphene, MoS<sub>2</sub>, etc)
- Extensive growth, characterization of material structure, photonic, and electronic properties
- Demonstration of novel device functionalities

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